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## THE UNITED STATES PATENT AND TRADEMARK OFFICE

JAN - 3 2003

In re the Application of:

TECHNOLOGY CENTER 2800

NIKAMI, Takashi

Group Art Unit: 2811

Serial No.: 10/084,925

Examiner: VU, Quang D.

Filed: March 1, 2002

P.T.O. Confirmation No.: 7137

For:

SEMICONDUCTOR DEVICE AND METHOD FOR FABRICATING THE SAME

## **AMENDMENT UNDER 37 CFR §1.111**

Commissioner for Patents Washington, D.C. 20231

January 2, 2003

Sir:

In response to the Office Action dated October 3, 2002, please amend the above-identified application as follows:

## **IN THE CLAIMS:**

Please CANCEL claims 5 and 10-12 without prejudice or disclaimer.

Please AMEND the claims as follows:

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1. (Amended) A semiconductor device, comprising:

a source region formed of a semiconductor;

a drain region for ned of a semiconductor of the same conductive type as that of said source region;

a channel region formed of a semiconductor between said source region and said drain region;

a gate insulating film provided on said channel region; and